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40% Increase in Sales for OAI for 2010

Fueled by Lithography Equipment for Production

February, 23, 2011 San Jose ,CA: OAI announces a 40% increase in sales for the year 2010. The growth was attributed to repeat orders for production equipment from major semiconductor companies as well as exports of MEMS front and backside lithography equipment.. "The loyalty of our customers and the reliability of our equipment combined, fueled by increased production needs, resulted in an increase in our production equipment orders." says Charles Turk, President OAI. The equipment ordered includes flood exposure systems and edge exposure systems for 300mm wafers.

OAI's line of precision lithography systems have proven reliability, versatility, while maintaining high throughput. The Automated Flood Exposure System has computer controlled windows based graphic user interface, is Semi S-2 compliant, and has cassette to cassette robotic handling. The Edge Bead Exposure System for 300mm production has automated FOUP handling and is also Semi S-2 compliant. All systems are engineered to the customers' specific requirements.

OAI is a Silicon Valley based manufacturer of advanced precision lithography equipment for over 35 years offering a portfolio of field proven products which include front and backside mask aligners both automated for production or manual for R&D, UV Exposure Systems, UV Light Sources, and Wafer Bonders for Semiconductor, MEMS and Nanotechnology. OAI maintains full sales, service and engineering offices worldwide.

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